

Application Industry: Sewage Treatment Textile Aid Industrial Cleaning

Product Name: Antifoam RK-03P

RK-03P is composed of polydimethylsiloxane and inorganic salt. It has outstanding bubble inhibition performance and good acid and alkaline resistance. It is used in sewage treatment, textile auxiliaries and industrial cleaning.

## **Product property:**

Outstanding bubble inhibition performance

Good acid and alkaline resistance

## Main physical and chemical properties:

Item	Range	
Appearance	White solid powder or particle	
pH value	4.0~8.0	

## **Application Process:**

RK-03P can be added directly and is not suitable for dilution. The addition amount is 0.1%~0.6%, and the best addition amount is determined according to the actual situation on site.

## **Key Applications**

Sewage treatment

Textile additives

Industrial cleaning

## **LIMITATIONS**

This product is neither tested nor represented as suitable for medical or pharmaceutical uses

# Information of manufacturers and products

Product name	Antifoam
Model	RK-03P
Manufacturer	Xiamen Rickman Chemical Technology CO., Ltd. Add: No1267Qianpu South Road, Siming District, Xiamen City,
	Fujian Province, China
Tel/Fax	15359255189



#### **Product content**

Pure or mixture	Mixture
English name	Polydimethylsiloxane, inorganic salt

## **Dangerous marks**

Human-body health effect	Skin	Slightly skin allergic for variety of	
	contact	people	
	Eye contact	Eye allergic	
	Swallow	No data	
Environment effect	No data		
Physical/chemical damage			
Special damage			

# **Packaging & Storage**

Package	25kg bag
Storage Condition	Room Temperature Storage (5°C-40°C), Avoid direct sun light, shelf
	life is 12 months.

## LIMITED WARRANTY INFORMATION – PLEASE READ CAREFULLY

The information contained here is offered in good faith and is believed to be accurate. However, because conditions and methods of use of Rickman products are beyond our control, this information should not be used in substitution for customer's tests to ensure that our products are safe, effective, and fully satisfactory for the intended end application.